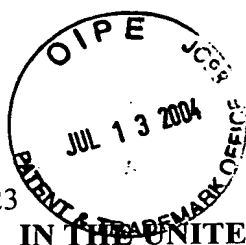


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IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re patent application of

Yasuhiro Sato, et al.

Serial No.: 09/897,909

Group Art Unit: 2826

Filing Date: July 5, 2001

Examiner: Sefer, Ahmed N.

For: REFLECTOR FORMED WITH HIGHLY RELIABLE CONDUCTIVE PATTERN,
PROCESS FOR FABRICATING REFLECTOR AND LIQUID CRYSTAL
DISPLAY UNIT USING THE SAME

Honorable Commissioner of Patents
Alexandria, Virginia 22313-1450

INFORMATION DISCLOSURE STATEMENT

Sir:

Under the provisions of 37 CFR §1.97 through §1.99 and pursuant to applicants' duty of disclosure under 37 CFR §1.56, applicants respectfully bring the following documents cited in the Taiwanese Office Action listed on the attached form PTO-1449, to the attention of the Examiner in charge of the above-identified application. Copies of the listed documents are provided herewith for the convenience of the Examiner.

In compliance with the requirements of 37 CFR §1.98(a)(3), as a concise statement of relevance, as it is presently understood by the individual designated in 35 U.S.C. §1.56(c) most knowledgeable about the content of the information, the undersigned attorney of record submits a translation of portions of an official action by a foreign examiner in which the references were cited. The relevance to the pending U.S. patent application is that the references were cited in a foreign patent application on the same subject matter. However, no independent analysis of the references, the accuracy of the statement of the foreign examiner or the claims of the foreign application under the laws of that country or the United States relative to the subject matter claimed in the present application has been made, the present understanding of the contents thereof by the undersigned being based on the translation of the foreign examiner's comments submitted herewith.

These citations do not constitute an admission that the references are relevant or material to the claims. They are only cited as constituting related art of which the applicants are aware.

I hereby certify that each item of information contained in this Information Disclosure Statement was the first citation of that item by a foreign patent office in a counterpart foreign application, which occurred not more than three months prior to the filing of this statement.

Serial No. 09/897,909
Docket No. N1122-U

2

It is respectfully requested that the listed references be considered by the Examiner and formally made of record in this application.

Please charge any deficiencies in fees and credit any overpayment of fees to Attorney's Deposit Account No. 50-0481.

Date: 7/13/04

Respectfully submitted,

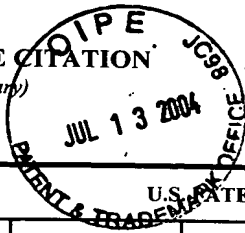
A handwritten signature in dark ink, appearing to read 'Fredric J. Zimmerman', with a long horizontal flourish extending to the right.

Fredric J. Zimmerman, Esq.
Registration No. 48,747

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Customer No. 21254

INFORMATION DISCLOSURE CITATION

(Use several sheets if necessary)



Docket Number (Optional)

NU1122-U

Application Number

09/897,909

Applicant(s)

Yasuhiro Sato, et al.

Filing Date

July 5, 2001

Group Art Unit

2826

U.S. PATENT DOCUMENTS

*EXAMINER INITIAL	REF	DOCUMENT NUMBER	DATE	NAME	CLASS	SUBCLASS	FILING DATE IF APPROPRIATE
		5,119,106	06/02/92	Murakami			
		5,609,704	03/11/97	Hayama, et al.			

U.S. PATENT APPLICATION PUBLICATIONS

*EXAMINER INITIAL	REF	DOCUMENT NUMBER	DATE	NAME	CLASS	SUBCLASS	FILING DATE IF APPROPRIATE

FOREIGN PATENT DOCUMENTS

	REF	DOCUMENT NUMBER	DATE	COUNTRY	CLASS	SUBCLASS	Translation	
							YES	NO
		10-206847	08/07/98	Japan (previously submitted)				

OTHER DOCUMENTS

(Including Author, Title, Date, Pertinent Pages, Etc.)

		Taiwanese Office Action dated May 25, 2004, with a partial English translation.

EXAMINER

DATE CONSIDERED

EXAMINER: Initial if citation considered, whether or not citation is in conformance with MPEP Section 609; Draw line through citation if not in conformance and not considered. Include copy of this form with next communication to applicant.